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Docket No.: 067161-0130

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Customer Number: 20277

Yoshikazu NAGAMURA, et al. : Confirmation Number: 1874

Application No.: 10/714,362 : Group Art Unit: 1756

Filed: November 17, 2003 : Examiner: Stephen Rosasco

For: PHOTOMASK, AND METHOD AND APPARATUS FOR PRODUCING THE SAME

INFORMATION DISCLOSURE STATEMENT

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached form PTO-1449. It is respectfully requested that the references be expressly considered during the prosecution of this application, and that the references be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

Each non-English language reference was first cited in a corresponding foreign application office action and its relevance discussed therein. A copy of the foreign office action, together with an English language version thereof, is attached for the Examiner's information.

10/714,362

Please charge any shortage in fees due in connection with the filing of this paper, including extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,

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Date: November 30, 2005

Please recognize our Customer No. 20277 as our correspondence address.



SHEET <u>1</u> OF <u>1</u>

| INFORMATION DISCLOSURE CITATION IN AN | | | | | | | | SERIAL NO. 10/714,362 | | |
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| APPLICATION | | | | | | | | | | |
| | | | | | APPLICANT Yoshikazu NAGAMURA, et al. | | | | | |
| (PTO-1449) | | | | | FILING DATE November | FILING DATE November 17, 2003 GROUP 1756 | | | | |
| U.S. PATENT DOCUMENTS | | | | | | | | | | |
| EXAMINER'S INITIALS | CITE NO. | | ocument Number er-Kind Code2 (# known) | Publication Date MM-DD-YYYY | | Name of Patentee or Applicant of Cited Document | | Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear | | |
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| INITIALS | CITE Country Codes | | y Codes-Number 4-Kind Codes (if known) | MM-DD-YYYY | Applicant of Cited Document | Lines Where Relevant Figures Appear | | Yes | No | |
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^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.